

Magneto-transport studies on $\text{La}_{2/3}\text{Ba}_{1/3}(\text{Mn}_{1-x}\text{Al}_x)\text{O}_3$ for low field sensing applications

ABSTRACT

The magnetic and transport properties of $\text{La}_{2/3}\text{Ba}_{1/3}(\text{Mn}_{1-x}\text{Al}_x)\text{O}_3$ ($x=0.0, 0.1, 0.2, 0.3$ and 0.4) compounds, prepared by the solid state reaction, have been investigated. Samples show a metal-insulator transition excluding the sample $x=0.0$. With increased Al doping, the metal-insulator transition temperature T_p is shifted to lower temperatures. Grain size reduction leads to a larger resistivity and a decrease in T_p . Upon analysing the data using several theoretical models, it was found that the metallic (ferromagnetic) part of the resistivity (below T_p) fits well with the equation $\rho = \rho_0 + \rho_1 T^2$, where ρ_0 is due to the importance of grain/domain boundary effects, and a second term $\rho_1 T^2$ might be attributed to the electron-electron scattering. The microstructure results indicate that the porosity of the samples increased when the concentration increased. The magnetoresistance (MR) is defined as $\%MR = 100 \times [\rho(H, T) - \rho(0, T)] / \rho(0, T)$, where $\rho(H, T)$ and $\rho(0, T)$ are the resistivities at temperature T , with an applied magnetic field H and zero applied magnetic field respectively. All samples show low-field magnetoresistance and high-field magnetoresistance regions. The highest percentage of LFMR at a temperature of 100 K is $\sim 210\%$ MR/Tesla, measured for the sample $x=0.2$. For $x=0.3$, the sample reveals the highest colossal magnetoresistance value among other doped compounds with 27.27% at 100 K.

Keyword: Metal-insulator transition temperature T_p ; Resistivity; Low-field magnetoresistance